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Reaction of (Me₃SiCH₂)₃Al with E(SiMe₃)₃ (E = P, As) in a 1:1 mole ratio affords the Lewis acid-base adducts (Me₃SiCH₂)₃Al•P(SiMe₃)₃ (1) and (Me₃SiCH₂)₃Al•As(SiMe₃)₃ (2). Similarly, the 1:1 mole ratio reaction of (Me₃CCH₂)₃Al with E(SiMe₃)₃ (E = P, As) leads to the isolation of (Me₃CCH₂)₃Al•P(SiMe₃)₃ (3) and (Me₃CCH₂)₃Al•As(SiMe₃)₃ (4). The adduct (Me₃SiCH₂)₂(Br)Al•P(SiMe₃)₃ (5) was obtained from the 1:1 mole ratio reaction of (Me₃SiCH₂)₂AlBr with P(SiMe₃)₃. The dimers [(Me₃SiCH₂)(Br)AlP(SiMe₃)₂]₂ (6) and [(Me₃SiCH₂)(Br)AlAs(SiMe₃)₂]₂ (7) were isolated as products of the lithium halide elimination reactions of (Me₃SiCH₂)AlBr₂ (10) with LiE(SiMe₃)₂ (E = P, As), while reaction of (Me₃SiCH₂)₂AlBr with these same lithium pnictide salts leads to the isolation of [(Me₃SiCH₂)₂AlP(SiMe₃)₂]₂ (8) and [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (9). Various physical and spectroscopic data, including a variable temperature NMR study of the dimeric compounds 6 through 9, are presented for the above compounds, as are the single crystal X-ray structures of 2 through 7 and 9.

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SYNTHESIS AND CHARACTERIZATION OF STERICALLY HINDERED ALKYLALUMINUM-PHOSPHORUS AND -ARSENIC COMPOUNDS. X-RAY CRYSTAL STRUCTURES OF (Me3ECH2)3Al•E'(SiMe3)3 (E = Si, E' = As; E = C, E' = P, As), (Me3SiCH2)2(Br)Al•P(SiMe3)3, AND [(Me3SiCH2)(X)AlE(SiMe3)2]2 (X = Br, E = P, As; X = Me3SiCH2, E = As).

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SYNTHESIS AND CHARACTERIZATION OF STERICALLY HINDERED

ALKYLALUMINUM-PHOSPHORUS AND -ARSENIC COMPOUNDS. X-RAY

CRYSTAL STRUCTURES OF (Me₃ECH₂)₃Al•E'(SiMe₃)₃ (E = Si, E' = As; E = C,

E' = P, As), (Me₃SiCH₂)₂(Br)Al•P(SiMe₃)₃, AND [(Me₃SiCH₂)(X)AlE(SiMe₃)₂]₂ (X =

Br, E = P, As; X = Me₃SiCH₂, E = As).

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Abstract- Reaction of $(Me_3SiCH_2)_3Al$ with $E(SiMe_3)_3$ (E = P, As) in a 1:1 mole ratio affords acid-base $(Me_3SiCH_2)_3Al \bullet P(SiMe_3)_3$ **(1)** the Lewis adducts and (Me₃SiCH₂)₃Al•As(SiMe₃)₃ (2). Similarly, the 1.1 mole ratio reaction of (Me₃CCH₂)₃Al with $E(SiMe_3)_3$ (E = P, As) leads to the isolation of $(Me_3CCH_2)_3Al \bullet P(SiMe_3)_3$ (3) and The adduct (Me₃SiCH₂)₂(Br)Al•P(SiMe₃)₃ (5) was $(Me_3CCH_2)_3Al \bullet As(SiMe_3)_3$ (4). obtained from the 1:1 mole ratio reaction of (Me₃SiCH₂)₂AlBr with P(SiMe₃)₃. The dimers $[(Me_3SiCH_2)(Br)AlP(SiMe_3)_2]_2$ (6) and $[(Me_3SiCH_2)(Br)AlAs(SiMe_3)_2]_2$ (7) were isolated as products of the lithium halide elimination reactions of (Me₃SiCH₂)AlBr₂ (10) with LiE(SiMe₃)₂ (E = P, As), while reaction of $(Me_3SiCH_2)_2AlBr$ with these same lithium pnictide salts leads to the isolation of [(Me₃SiCH₂)₂AlP(SiMe₃)₂]₂ (8) and [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (9). Various physical and spectroscopic data, including a variable temperature NMR study of the dimeric compounds 6 through 9, are presented for the above compounds, as are the single crystal X-ray structures of 2 through 7 and 9.

Introduction

The bulk of research in our laboratory over the past decade has focused on the synthesis and characterization of potential single-source precursor compounds to Group 13-Group 15 materials, obtained predominately through dehalosilylation and lithium-halide elimination reactions. In an attempt to prepare compounds which may serve as precursors to aluminum-phosphides and -arsenides, we have become interested in the synthesis of novel compounds containing this 13-15 linkage. For example, we have recently reported the isolation of the Lewis acid-base adducts $X_3^*Al \bullet E(SiMe_3)_3$ (X = Cl and Br, E = P^1 ; X = Cl, E = As^2) and $Ph_3Al \bullet E(SiMe_3)_3$ (E = P and As^3), as well as the ring-compounds

[Et₂AlE(SiMe₃)₂]₂ (E = P⁴ and As⁵). In the present study, we undertook the synthesis of a series of aluminum compounds containing the bulkier (trimethylsilyl)methyl and neo-pentyl ligands. While these starting materials have been known for some time, relatively little chemistry has been performed with them, especially in the area of 13-15 precursor compounds. A comparison of these results with a similar series of reactions involving the heavier metals gallium and indium⁶ would be of interest. Additionally, we wished to probe the feasibility of trimethylsilyl bromide elimination in the synthesis of aluminum-phosphorus and -arsenic compounds.

Experimental Section

General Considerations: All manipulations of air- and moisture-sensitive materials were performed in a Vacuum Atmospheres HE-493 Dri-Lab containing an argon atmosphere or by standard Schlenk techniques. Pentane, hexane, toluene, and THF were distilled over sodium/potassium alloy under dry dinitrogen. (Me₃SiCH₂)₃Al⁷, (Me₃SiCH₂)₂AlBr⁸, (Me₃CCH₂)₃Al⁹. P(SiMe₃)₃¹⁰, and As(SiMe₃)₃¹¹ were prepared from literature procedures. LiP(SiMe₃)₂¹² and LiAs(SiMe₃)₂¹¹ were prepared from the 1:1 reaction of P(SiMe₃)₃ or As(SiMe₃)₃ with LiCH₃ in THF. AlBr₃ was purchased from Strem Chemicals, Inc. and purified through sublimation. The integrity of all starting materials was confirmed using ¹H NMR spectroscopy. ¹H. ¹³C{¹H}, and ³¹P{¹H} NMR spectra were recorded on a Varian Unity XL-400 spectrometer operating at 400, 100.6, and 161.9 Mhz, respectively. ¹H and ¹³C{¹H} spectra were referenced to TMS using the residual protons or carbons of deuterated benzene at δ 7.15 or δ 128.0, respectively. ³¹P{¹H} spectra were referenced externally to 80% H₃PO₄ at δ 0.00. All NMR samples were prepared in 5-mm tubes

which were septum-sealed under argon or flame sealed under vacuum (in the case of the variable temperature experiments). Melting points (uncorrected) were obtained with a Thomas-Hoover Uni-melt apparatus, using capillaries that were flame-sealed under argon. Elemental analyses were performed by E+R Microanalytical Laboratory, Inc., Corona, NY.

Preparation of (Me₃SiCH₂)₃Al•P(SiMe₃)₃ (1): (Me₃SiCH₂)₃Al (0.288 g; 1.00 mmol) was added with 20 mL of hexane to a 250 mL flask equipped with a stir bar and Teflon valve. P(SiMe₃)₃ (0.250 g; 1.00 mmol) in 30 mL of hexane was added slowly via pipet, and the clear colorless solution stirred for 6 h at room temperature. The volatiles were removed *in vacuo*, yielding a white solid which was extracted with warm pentane and allowed to evaporate at -30 °C, producing colorless crystals of 1 (0.468 g, 86% yield). m.p. 95 - 99 °C. Anal. Calcd. (found) for C₂₁H₆₀AlPSi₆: C, 46.78 (46.46); H, 11.22 (11.41). ¹H NMR: δ -0.46 (s, 6H. Me₃SiCH₂-), δ 0.27 [d, 27H, -SiMe₃ (J_{P-H} = 4.4 Hz)], δ 0.31 (s, 27H, Me_3 SiCH₂-). ¹³C(¹H) NMR: δ 3.33 (s, Me₃SiCH₂-), δ 3.45 (s, Me_3 SiCH₂-), δ 3.66 [d, -SiMe₃ (J_{P-C} = 9.1 Hz)]. ³¹P(¹H) NMR: δ -240.86 (s).

Preparation of (Me₃SiCH₂)₃Al•As(SiMe₃)₃ (2): The procedure used was identical to that described for 1. (Me₃SiCH₂)₃Al (0.288 g; 1.00 mmol); As(SiMe₃)₃ (0.294 g; 1.00 mmol). (Me₃SiCH₂)₃Al•As(SiMe₃)₃ (2) (0.554 g, 95% yield). m.p. 89 - 95 °C. Anal. Calcd. (found) for $C_{21}H_{60}AlAsSi_6$: C, 43.25 (42.88); H, 10.37 (10.11). ¹H NMR: δ -0.42 (s, 6H, Me₃SiCH₂-), δ 0.29 (s, 27H, Me₃SiCH₂-), δ 0.32 (s, 27H, -SiMe₃). ¹³C{¹H} NMR: δ 3.37 (s, Me₃SiCH₂-), δ 3.97 (s, -SiMe₃).

Preparation of (Me₃CCH₂)₃Al•P(SiMe₃)₃ (3): (Me₃CCH₂)₃Al (0.240 g; 1.00 mmol) was added with 20 mL of hexane to a 250 mL flask equipped with a stir bar and Teflon valve. P(SiMe₃)₃ (0.250 g; 1.00 mmol) in 30 mL of hexane was added slowly via pipet, and the clear colorless solution stirred for 12 h at room temperature. The solvent level was reduced *in vacuo* and allowed to evaporate at -30 °C, producing colorless crystals of 3 (0.431 g, 88% yield). m.p. 115 - 117 °C. Anal. Calcd. (found) for C₂₄H₆₀AlPSi₃: C, 58.72 (58.63); H, 12.32 (12.16). ¹H NMR: δ 0.31 [d, 27H, -SiMe₃ ($J_{P-C} = 4.4 \text{ Hz}$)], δ 0.66 (s, 6H. Me₃CCH₂-), δ 1.28 (s, 27H, Me_3 CCH₂-). ¹³C{¹H} NMR: δ 32.64 (s, Me₃CCH₂-), δ 35.51 (s, Me_3 CCH₂-), δ 3.82 [d, -SiMe₃ ($J_{P-C} = 9.1 \text{ Hz}$)]. ³¹P{¹H} NMR: δ -241.34 (s).

Preparation of (Me₃CCH₂)₃Al•As(SiMe₃)₃ (4): The procedure used was identical to that described for 3. (Me₃CCH₂)₃Al (0.240 g; 1.00 mmol); As(SiMe₃)₃ (0.294 g; 1.00 mmol). (Me₃CCH₂)₃Al•As(SiMe₃)₃ (4) (0.422 g, 79% yield). m.p. 114 - 117 °C. Anal. Calcd. (found) for C₂₄H₆₀AlAsSi₃: C, 53.89 (53.66); H, 11.31 (11.27). ¹H NMR: δ 0.34 (d, 27H, -SiMe₃), δ 0.64 (s, 6H, Me₃CCH₂-), δ 1.20 (s, 27H, Me₃CCH₂-). ¹³C{¹H} NMR: δ 4.15 (s, -SiMe₃), δ 32.19 (s, Me₃CCH₂-), δ 35.33 (s, Me₃CCH₂-).

Preparation of (Me₃SiCH₂)₂(Br)Al•P(SiMe₃)₃ (5): The procedure used was identical to that described for 3. (CH₂SiMe₃)₂AlBr (0.281 g; 1.00 mmol); P(SiMe₃)₃ (0.250 g; 1.00 mmol). (Me₃SiCH₂)₂(Br)Al•P(SiMe₃)₃ (5) (0.301 g, 57% yield). m.p. 94 - 100 °C. Anal. Calcd. (found) for C₁₇H₄₉AlPBrSi₅: C, 38.39 (38.47); H, 9.29 (9.26). ¹H NMR: δ -0.45 (s, 4H, Me₃SiCH₂-), δ 0.28 [d, 27H, -SiMe₃ (J_{P-H} = 4.8 Hz)], δ 0.31 (s,

18H, $Me_3 \text{SiCH}_{2^-}$). ¹³C{¹H} NMR: δ 3.33 (s, Me₃SiCH₂-), δ 3.44 (s, $Me_3 \text{SiCH}_{2^-}$), δ 3.65 [d. -SiMe₃ ($J_{P-C} = 10.3 \text{ Hz}$)]. ³¹P{¹H} NMR: δ -225.28 (s).

Preparation of [(Me₃SiCH₂)(Br)AlP(SiMe₃)₂]₂ (6): (Me₃SiCH₂)AlBr₂ (0.411 g; 1.50 mmol) was added with 20 mL of hexane to a 250 mL flask equipped with a stir bar and Teflon valve. To this stirred room temperature solution was added LiP(SiMe₃)₂•.6 THF (0.340 g; 1.50 mmol). Within minutes, a hazy red color developed, and stirring was continued for 12 h. At the end of this time, the LiCl was allowed to settle, and the red solution was transferred to a second flask via cannula. The solvent volume was reduced *in vacuo*, and allowed to evaporate at -30 °C. Within 24 h, clear, colorless crystals of 6 (0.265 g, 71% yield) had formed. m.p. 187 - 192 °C. Anal. Calcd. (found) for C₂₀H₅₈Al₂P₂Br₂Si₆: C, 32.33 (32.45); H, 7.87 (7.93). ¹H NMR: δ -0.06 (bs, 4H, Me₃SiCH₂-), δ 0.36 (s. 18H, Me₃SiCH₂-), δ 0.49 [t, 36H, -SiMe₃ (J_{P-H} = 2.8 Hz)]. ¹³C{¹H} NMR: δ 2.95 (s. Me₃SiCH₂-), δ 4.13 [t, -SiMe₃ (J_{P-C} = 4.9 Hz)]. ³¹P{¹H} NMR: δ -215.15 (s).

Preparation of [(Me₃SiCH₂)(Br)AlAs(SiMe₃)₂]₂ (7): The procedure used was identical to that described for 6. (CH₂SiMe₃)AlBr₂ (0.274 g; 1.00 mmol); LiAs(SiMe₃)₂•.6 THF (0.270 g; 1.00 mmol). [(Me₃SiCH₂)(Br)AlAs(SiMe₃)₂]₂ (7) (0.310 g. 75% yield). m.p. 189 - 191 °C (decomposed to an orange liquid). Anal. Calcd. (found) for C₂₀H₅₈Al₂As₂Br₂Si₆: C. 28.91 (28.73); H, 7.04 (6.72). ¹H NMR: δ -0.01 (s, 4H, Me₃SiCH₂-), δ 0.37 (s, 18H, Me₃SiCH₂-), δ 0.52 (s, 36H, -SiMe₃). ¹³C{¹H} NMR: δ 2.87 (s, Me₃SiCH₂-), δ 4.13 (s, -SiMe₃).

Preparation of [(Me₃SiCH₂)₂AlP(SiMe₃)₂]₂ (8): The procedure used was identical to that described for 6. (CH₂SiMe₃)₂AlBr (0.281 g; 1.00 mmol); LiP(SiMe₃)₂•.6 THF (0.227 g; 1.00 mmol). [(Me₃SiCH₂)₂AlP(SiMe₃)₂]₂ (8) (0.266 g, 70% yield). m.p. 190 - 198 °C. Anal. Calcd. (found) for C₂₈H₈₀Al₂P₂Si₈: C, 44.39 (44.19); H, 10.64 (10.79). ¹H NMR: δ -0.18 (bs, 8H, Me₃SiCH₂-), δ 0.35 (s, 36H, Me₃SiCH₂-), δ 0.48 [t, 36H, -SiMe₃ ($J_{P-H} = 2.4 \text{ Hz}$)]. ¹³C{¹H} NMR: δ 2.48 (bs, Me₃SiCH₂-), δ 4.11 (s, Me_3 SiCH₂-), δ 5.28 [t, -SiMe₃ ($J_{P-C} = 4.1 \text{ Hz}$)]. ³¹P{¹H} NMR: δ -234.97 (s).

Preparation of [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (9): The procedure used was identical to that described for 6. (Me₃SiCH₂)₂AlBr (0.281 g; 1.00 mmol); LiAs(SiMe₃)₂•.6 THF (0.270 g; 1.00 mmol). [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (9) (0.326 g, 77% yield). m.p. 201 - 212 °C (decomposed to a yellow liquid). Anal. Calcd. (found) for $C_{28}H_{80}Al_2As_2Si_8$: C, 39.78 (39.77); H, 9.54 (9.79). ¹H NMR: δ -0.13 (s, 8H, Me₃SiCH₂-), δ 0.35 (s, 36H. Me_3SiCH_2 -), δ 0.51 (s, 36H, -SiMe₃). ¹³C{¹H} NMR: δ 2.89 (s, Me₃SiCH₂-), δ 3.39 (s, Me_3SiCH_2 -), δ 5.19 (s, -SiMe₃).

Preparation of (Me₃SiCH₂)AlBr₂ (10): (Me₃SiCH₂)₃Al (1.00 g; 3.5 mmol) in 30 mL of hexane was added to a 250 mL flask equipped with a stir bar and Teflon valve. AlBr₃ (1.80 g; 7.00 mmol) in 50 mL of hexane was added to the clear colorless solution, and stirring was continued at room temperature for 48 h. The solvent was removed *in vacuo*, and 10 was isolated as a clear, colorless liquid (1.60 g, 93% yield). ¹H NMR: δ -0.29 (s, 2H, Me₃SiCH₂-), δ 0.09 (s, 9H, Me₃SiCH₂-). ¹³C{¹H} NMR: δ 1.75 (s, Me₃SiCH₂-).

¹H NMR Equilibration of 6 and 7: In a drybox, 6 (9.8 mg, 0.03 mmol) and 7 (11.0 mg, 0.03 mmol) were each dissolved separately in 0.37 mL of toluene- d_8 . The two solutions were then added to the same NMR tube via pipet, and the tube flame sealed. An initial spectrum was taken, after which the sealed tube was placed in an oil bath at 70 °C. Spectra were recorded every 24 h for a period of 7 d. ¹H NMR (initial): δ -0.09 (bs, 4H, Me₃SiCH₂-, 6), δ -0.03 (s, 4H, Me₃SiCH₂-, 7), δ 0.33 (s, 36H, Me_3 SiCH₂-, 6 and 7), δ 0.50 [t, 36H, -SiMe₃ ($J_{P-H} = 2.6$ Hz), 6], δ 0.52 (s, 36H, -SiMe₃, 7). ³¹P{¹H} NMR (initial): δ -214.20 (s, 6). ¹H NMR (final): δ -0.09 (bs, Me₃SiCH₂-, 6), δ -0.07 (bs), δ -0.03 (s, Me₃SiCH₂-, 7), δ 0.33 (s, Me_3 SiCH₂-, 6 and 7), δ 0.49 (d, $J_{P-H} = 5.2$ Hz), δ 0.50 [t, -SiMe₃ ($J_{P-H} = 2.6$ Hz), 6], δ 0.52 (s, -SiMe₃, 7), δ 0.53 (s). ³¹P{¹H} NMR (final): δ -214.23 (s, 6), δ -209.73 (s).

¹H NMR Equilibration of 8 and 9: The procedure used was identical to that described for 6 and 7. ¹H NMR (initial): δ -0.20 (bs, 8H, Me₃Si*CH*₂-, 8), δ -0.15 (s, 8H, Me₃Si*CH*₂-, 9), δ 0.34 (s, 72H, Me_3 SiCH₂-, 8 and 9), δ 0.48 [t, 36H, -SiMe₃ ($J_{P-H} = 2.4$ Hz), 8], δ 0.52 (s, 36H, -SiMe₃, 9). ³¹P{¹H} NMR (initial): δ -234.97 (s). ¹H NMR (final): δ -0.15 (s, Me₃Si*CH*₂-, 9), δ 0.23 (d, $J_{P-H} = 4.4$ Hz), δ 0.34 (s, Me_3 SiCH₂-, 8 and 9), δ 0.48 (d, $J_{P-H} = 4.8$ Hz), δ 0.48 [t, -SiMe₃ ($J_{P-H} = 2.4$ Hz), 8], δ 0.52 (s, -SiMe₃, 9). ³¹P{¹H} NMR (final): δ -234.18 (s), δ -230.19 (s), δ -226.25 (s).

High-Temperature ¹H NMR Study of 6: In a drybox, a NMR sample was prepared by dissolving a small amount of the crystalline solid (approximately 20.0 mg) in 0.75 mL of toluene- d_8 , and adding the solution to the NMR tube via pipet. The tube was then flame sealed. ¹H NMR spectra were recorded at 25, 40, 60, 80, and 95 °C, allowing

5 min for equilibration at each temperature. The sample was then cooled, and spectra recorded at 60 °C and 25 °C. ¹H NMR (95 °C): δ -0.13 (bs, 4H, Me₃SiCH₂-), δ 0.28 (s, 18H, Me₃SiCH₂-), δ 0.50 [t, 36H, -SiMe₃ (J_{P-H} = 4.0 Hz)].

High-Temperature ¹H NMR Study of 7: The procedure used was similar to that described for 6. ¹H NMR (90 °C): δ -0.07 (s, 4H, Me₃SiCH₂-), δ 0.28 (s, 18H, Me₃SiCH₂-), δ 0.53 (s, 36H, -SiMe₃).

X-ray structural solution and refinement

Crystallographic data are summarized in Table 1, while Table 2 lists selected bond lengths and bond angles. The structural analyses were performed as follows: Compound 2: A single crystal of 2 was mounted on a glass fiber with a viscous oil under a stream of cold dinitrogen. X-ray intensity data were recorded at -135 °C on a Rigaku AFC6/S diffractometer utilizing graphite-monochromated Mo-K α radiation (λ = 0.71073 Å) and the structure was solved by direct methods. Full-matrix least-squares refinement with weights based upon counting-statistics was performed. Hydrogen atoms were incorporated at their calculated positions using a riding model in the later iterations of refinement which converged at R = 0.044 (R_w = 0.056). A final difference Fourier synthesis revealed no unusual features. Crystallographic calculations were performed using the NRCVAX¹³ suite of structure determination programs. For all structure-factor calculations, neutral atom scattering factors and their anomalous dispersion corrections were taken from ref. 14. An ORTEP¹⁵ diagram showing the solid-state confirmation and atom numbering scheme for 2 is shown in Figure 1.

Compounds 3, 4, 5, 6, 7 and 9: Suitable crystals were selected and mounted in

nitrogen-flushed glass capillaries and flame-sealed. The unit-cell parameters were obtained by the least-squares refinement of the angular settings of 24 reflections (20° ≤ $2\theta \le 24^{\circ}$). The systematic absences in the diffraction data are consistent with the trigonal space groups $P\overline{3}$ and P3 for 3 and 4, uniquely consistent for the space group $P2_1/c$ for 5, 6, and 7, and uniquely consistent for the space group Pbcn for 9. Solution in both the centrosymmetric and the chiral option were pursued for 3 and 4, but only solution in the chiral space group, P3, afforded chemically reasonable and computationally stable results of refinement. The structures were solved using direct methods, completed by subsequent difference Fourier syntheses and refined by full-matrix least-squares procedures. Semi-empirical ellipsoid absorption corrections were not necessary because there was less than 10% intensity variation in the y-scan data. There are three independent, but chemically equivalent molecules in the asymmetric unit for 3 and 4. The molecule in 6 and 7 lies on a crystallographic inversion center, and the molecule in 9 is located on a two-fold axis. The absolute configuration of 3 was determined (Flack = 0.2(2)) and 4 was refined as a 70/30 racemic twin. All non-hydrogen atoms were refined with anisotropic displacement coefficients, except for the carbon atoms of 4 and carbon atoms on the trimethysilyl groups of 5 which were refined isotropically to conserve data. Hydrogen atoms were treated as idealized contributions. Structures 3 and 4, and 6 and 7 are isomorphous.

All software and sources of the scattering factors are contained in the SHELXTL (Version 5.3) program library (G. Sheldrick, Siemens XRD, Madison, WI).

Results and Discussion

The room temperature, 1:1 reactions of (Me₃SiCH₂)₃Al with P(SiMe₃)₃ and As(SiMe₃)₃ yield the expected Lewis acid-base adducts (Me₃SiCH₂)₃Al•P(SiMe₃)₃ (1) and (Me₃SiCH₂)₃Al•As(SiMe₃)₃ (2), respectively. These adducts have been characterized through multinuclear NMR, partial elemental analysis, and, in the case of 2, single crystal X-ray analysis. Repeated attempts to recrystallize 1 failed to yield X-ray quality crystals. These reactions are analogous to those used previously to form (Me₃SiCH₂)₃M•P(SiMe₃)₃ and $(Me_1SiCH_2)_3M \bullet As(SiMe_3)_3$, where $M = Ga^{6e}$ or In^{16} . The (trimethylsilyl)methylgroups on the aluminum and the trimethylsilyl- groups on the arsenic of 2 adopt a staggered conformation to one another, and both the aluminum and arsenic reside in distorted tetrahedral environments. The Al-As bond length of 2.671(3) Å is well within the expected range, and compares favorably with the average Al-As distance of 2.60 Å reported for the adduct Ph₃Al•As(SiMe₃)₃³. The slightly longer bond length in 2 can be attributed to the greater steric bulk of the alkyl- groups around the aluminum when compared to the phenyl- groups. These phenyl- groups are also electron withdrawing, serving to increase the Lewis acidity of the aluminum and decrease the bond length. The average As-Al-C bond angle of 101.0° in 2 is also smaller than the corresponding average angle of 104.5° seen in Ph₃Al•As(SiMe₃)₃.

Similarly, the independent 1:1 reactions of (Me₃CCH₂)₃Al with P(SiMe₃)₃ and As(SiMe₃)₃ at room temperature in hexane solution result in a high yield of the Lewis acid-base adducts (Me₃CCH₂)₃Al•P(SiMe₃)₃ (3) and (Me₃CCH₂)₃Al•As(SiMe₃)₃ (4). Again, the (trimethylsilvl)methyl- and trimethylsilyl- groups adopt a staggered

conformation with respect to one another, and the aluminum and pnicogen atoms reside in distorted tetrahedral environments. The average Al-P bond length of 2.67 Å found in 3 is longer than the analogous Al-P distance of 2.52 Å found in Ph₃Al•P(SiMe₃)₃, again due to the decreased steric bulk and electron withdrawing nature of the phenyl- group. The average Al-As bond length of 2.72 Å found in 4 is comparable to the Al-As bond length of 2.671(3) Å in 2, due to the similarity of the ligands attached to the aluminum atoms.

The 1:1 mixture of (Me₃SiCH₂)₂AlBr and P(SiMe₃)₃ fails to undergo intermolecular dehalosilylation at room temperature, and instead affords the Lewis acid-base adduct (Me₃SiCH₂)₂(Br)Al•P(SiMe₃)₃ (5). This result is not surprising, and the failure of aluminum to participate in dehalosilylation reactions has been well documented^{3,17}, especially in the case of aluminum-phosphorus linkages. The isolation of 5 shows that the trend holds for this system as well. The Al-P bond length of 2.498(7) Å is very close to the analogous length in a similar structure, Ph₂ClAl•P(SiMe₃)₃, found to be 2.467(2) Å. Another interesting comparison between these structures is the P-Al-Halogen bond angle of 100.7(2)° in 5 and 102.1(1)° in Ph₂ClAl•P(SiMe₃)₃, where the increased size of the bromine atom combined with the increased steric bulk of the (trimethylsilyl)methyl- groups appears to have a small effect. The aluminum and phosphorus atoms in 5, as expected, reside in distorted tetrahedral environments with the attached groups adopting a staggered conformation.

The 1:1 salt-elimination reactions between (Me₃SiCH₂)AlBr₂ (10) and LiP(SiMe₃)₂ and LiAs(SiMe₃)₂ yield the anticipated dimers [(Me₃SiCH₂)(Br)AlP(SiMe₃)₂]₂ (6) and [(Me₃SiCH₂)(Br)AlAs(SiMe₃)₂]₂ (7), respectively. The synthesis of 10 was effected by

comproportionation between (Me₃SiCH₂)₃Al and AlBr₃. Similarly, reaction of (Me₃SiCH₂)₂AlBr LiP(SiMe₃)₂ with and LiAs(SiMe₃)₂ yielded the dimers [(Me₃SiCH₂)₂AlP(SiMe₃)₂]₂ (8) and [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (9), respectively. Their structures were determined by single crystal X-ray diffraction, except for 8. suggested dimer structure of 8 is based solely on the triplet present in the ¹H NMR spectrum, which appears as a result of virtual coupling of the trimethylsilyl- protons to the two phosphorus atoms in the central ring. Attempts to isolate X-ray quality crystals of this compound were unsuccessful. The average Al-P bond length of 2.44 Å in 6 is very close to the average Al-P bond length of 2.46 Å found in the dimer [Et₂AlP(SiMe₃)₂]₂⁴. The average endocyclic ring angles in 6 are 89.4° for Al-P-Al and 90.6° for P-Al-P, and the central Al-P-Al-P ring is planar as evidenced by the inversion center present in the The (trimethylsilvl)methyl- groups and bromine atoms also adopt a trans conformation in relation to one another. In 7, the average Al-As bond length of 2.51 Å also compares well with the average length of 2.53 Å reported for the dimer [Et₂AlAs(SiMe₃)₂]₂⁵. The exocyclic bromine atoms are again in a trans conformation, and the endocyclic ring angles are 90.15(9)° for Al-As-Al and 89.85(9)° for As-Al-As. Again, the inversion center present in the molecule demonstrates the planarity of this central ring. The average Al-As bond length of 2.57 Å and the average Al-As-Al and As-Al-As endocyclic ring angles of 92.9° and 87.2°, respectively, of 9 compare well with the analogous lengths and angles reported for 7 and the dimer [Et2AlAs(SiMe3)2]2 (vide supra).

In an attempt to study the solution behavior of these dimeric compounds, and judge the utility of equilibrating them to form a mixed-pnicogen type structure as in Et₂AIP(SiMe₃)₂Al(Et)₂As(SiMe₃)₂¹⁸ two independent NMR tube equilibration reactions were attempted, the first between 6 and 7 and the second between 8 and 9. Repeated scans of the samples at room temperature revealed no change in the peak multiplicities, positions, or integrations. However, heating the samples to 70 °C for 7 days resulted in a significant change in both samples. In the case of 6 and 7, the triplet assigned to the -SiMe₃ protons of 6 lost intensity, and a new doublet appeared in this same region at δ $0.49 (J_{P-H} = 5.2 \text{ Hz})$, superimposed on the triplet. Two new singlets also appeared in the ¹H spectra, at δ -0.07 and 0.53. In addition, a new peak was observed in the ³¹P{¹H} NMR spectra, at δ -209.72. Presumably, these new peaks arise from and are consistent with the formation of the desired mixed-pnicogen structure. However, the compound seems to be in equilibrium with the starting dimers, since there was no noticeable change in the spectra after 4 days, and all three compounds still were present. In the equilibration of dimers 8 and 9, no mixed-pnicogen structure was observed on heating, but 8 decomposed. This is shown most clearly by the rapid reduction in intensity of the triplet assigned to the -SiMe₃ protons of 8 in comparison to the -SiMe₃ protons of 9. This triplet was replaced with a doublet centered at δ 0.48 (J_{P-H} = 4.8 Hz), apparently due to the decomposition product.

In the only recorded cases of internal dehalosilylation by aluminum-arsenic compounds, trimethylsilylchloride elimination was induced by heating a sample of Cl₃Al•As(SiMe₃)₃ in a cool flame¹⁹, or by heating Et₂(Cl)Al•As(SiMe₃)₃ at 87 °C in an

NMR tube⁵. Both a bromine atom and a trimethylsilyl- group are present in 6 and 7. allowing for the potential loss of trimethylsilyl bromide to form a cubane or rearrange to another novel structure. In order to explore this possibility, a high temperature ¹H NMR study of 6 and 7 was undertaken. Since it was of interest to isolate an intermediate compound as opposed to the aluminum-pnictide, these studies were done at the same temperature used to initiate elimination in Et₂(Cl)Al•As(SiMe₃)₃ (vide supra). In both cases, no trimethylsilyl bromide elimination occurred. Both dimers maintained their integrity, as there was no change in the spectra up to 95 °C (for 6) or 90 °C (for 7). In fact, the triplet in the spectra of 6 due to the trimethylsilyl- protons was still present, indicating the dimeric structure of this compound is maintained at the higher temperature. A notable difference between 6 and 7 and Et₂(Cl)Al•As(SiMe₃)₃ is that in the present study, the attempted intramelecular dehalosilylation involves loss of the "second" trimethylsilyl- group from the phosphorus or arsenic atom. While P(SiMe₃)₃ and As(SiMe₃)₃ readily participate in room temperature dehalosilylation reactions, it has been seen in our laboratory that loss of a second or third trimethylsilyl- group is often difficult, requiring progressively higher temperatures²⁰. Considering this, as well as the unwillingness of aluminum to participate in dehalosilylation reactions in general, the stability of 6 and 7 at increased temperatures can be understood.

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Supplementary Material Available: Tables of bond distances, bond angles, anisotropic temperature factor parameters, and fractional coordinates for 2 through 7 and 9 (45 pages). Ordering information is given on any current masthead page.

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Captions to Figures

Figure 1. ORTEP diagram (30% probability ellipsoids) showing the solid-state structure and atom numbering scheme for (Me₃SiCH₂)₃Al•As(SiMe₃)₃ (2). Hydrogen atoms are omitted for clarity.

Figure 2. ORTEP diagram of (Me₃CCH₂)₃Al•P(SiMe₃)₃ (3) showing atom labelling scheme. Only one of the three independent, but chemically equivalent molecules are shown. Thermal ellipsoids at 30% probability and hydrogen atoms are omitted for clarity.

Figure 3. ORTEP diagram of (Me₃CCH₂)₃Al•As(SiMe₃)₃ (4) showing atom labelling scheme. Only one of the three independent, but chemically equivalent molecules are shown. Thermal ellipsoids at 30% probability and hydrogen atoms are omitted for clarity.

Figure 4. ORTEP diagram of (Me₃SiCH₂)₂(Br)Al•P(SiMe₃)₃ (5) showing atom labelling scheme. Thermal ellipsoids at 30% probability and hydrogen atoms are omitted for clarity.

Figure 5. ORTEP diagram of [(Me₃SiCH₂)(Br)AlP(SiMe₃)₂]₂ (6) showing atom labelling scheme. Thermal ellipsoids at 30% probability and hydrogen atoms are omitted for clarity.

Figure 6. ORTEP diagram of [(Me₃SiCH₂)(Br)AlAs(SiMe₃)₂]₂ (7) showing atom labelling scheme. Thermal ellipsoids at 30% probability and hydrogen atoms are omitted for clarity.

Figure 7. ORTEP diagram of [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (9) showing atom labelling scheme. Thermal ellipsoids at 30% probability and hydrogen atoms are omitted for clarity.

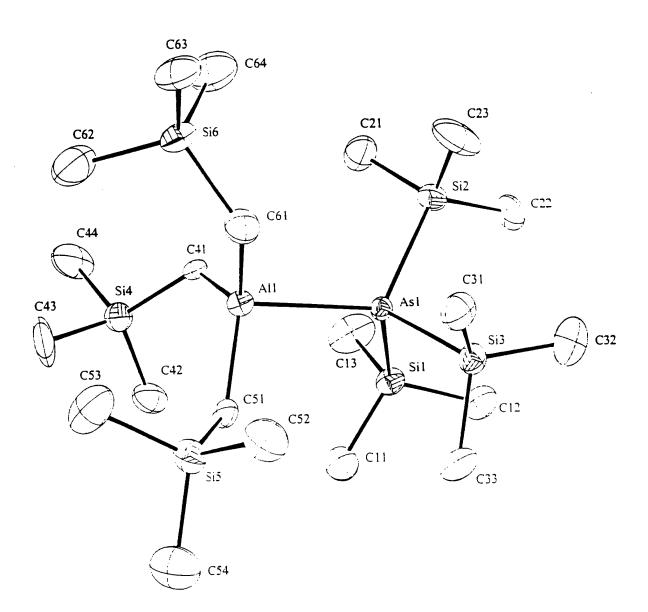


Figure 1.

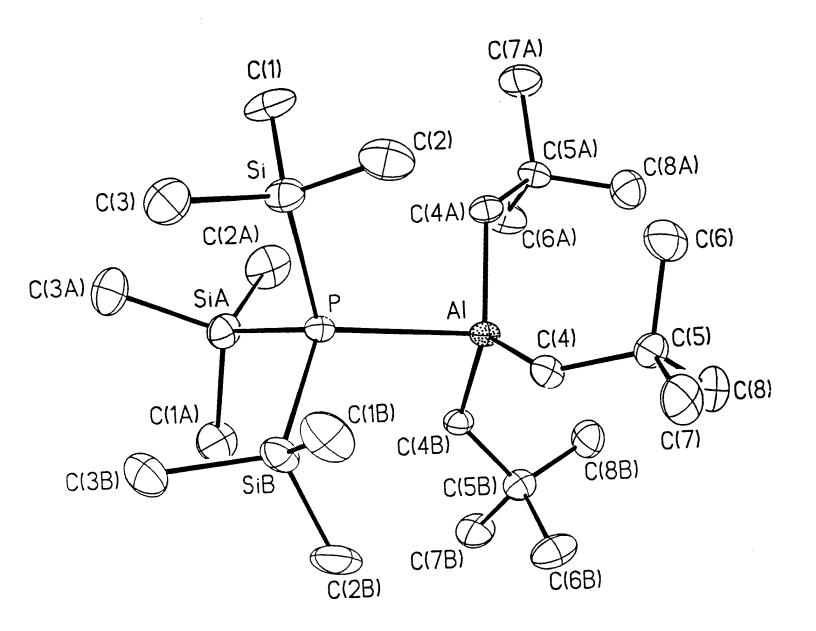


Figure 2.

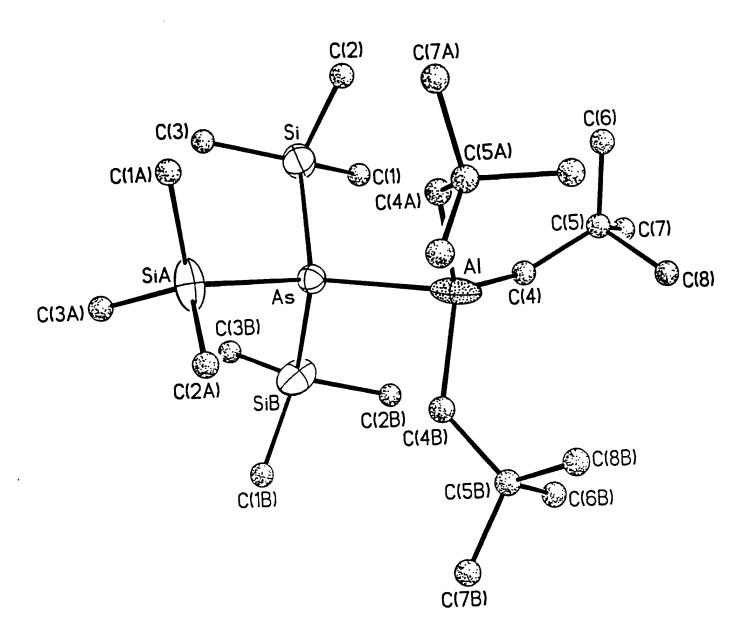


Figure 3.

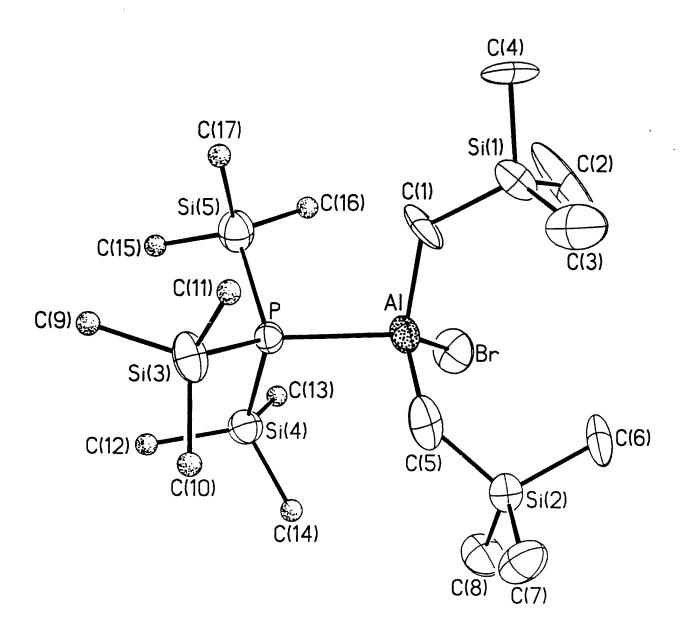


Figure 4.

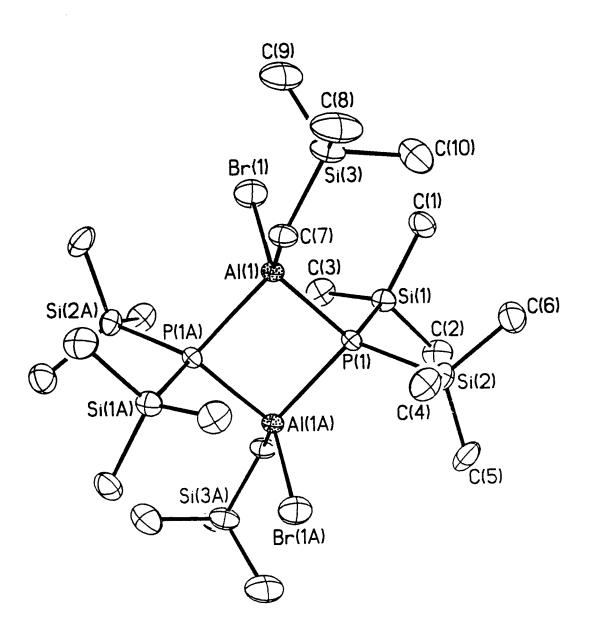


Figure 5.

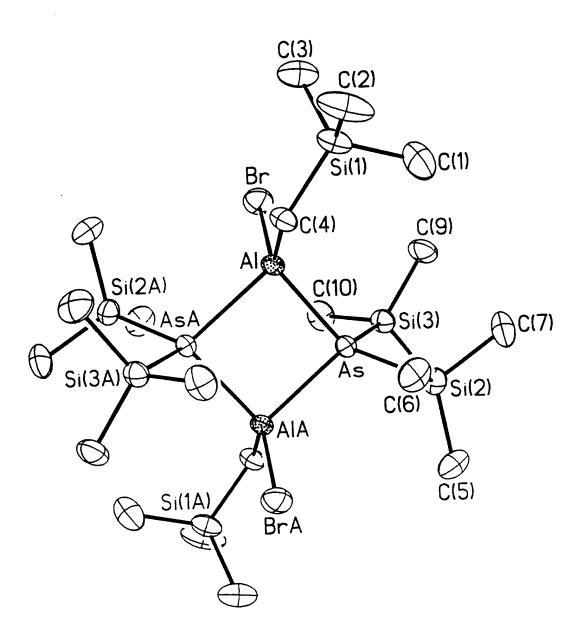


Figure 6.

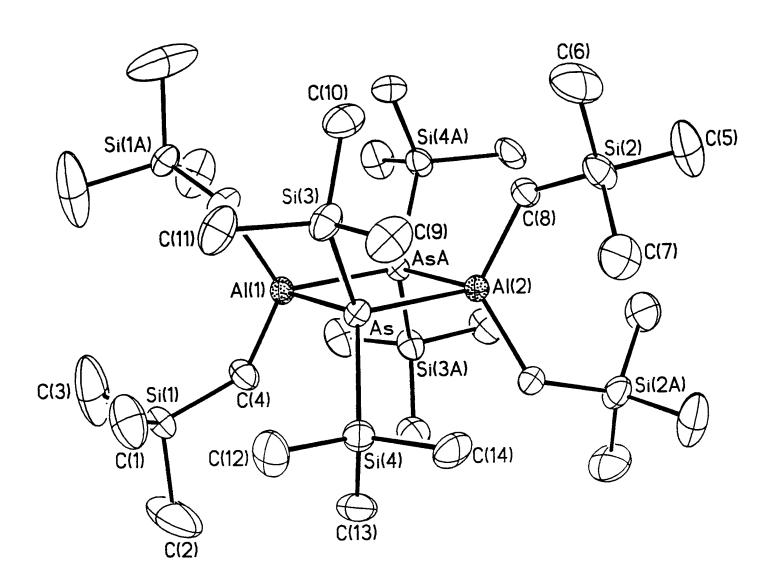


Figure 7.

Table 1. Crystallographic Data for (Me₃CCH₂)₃Al•P(SiMe₃)₃ (3), (Me₃CCH₂)₃Al•As(SiMe₃)₃ (4), (Me₃SiCH₂)₃(Br)Al•P(SiMe₃)₃ (5), [Me₃SiCH₂)(Br)AlP(SiMe₃)₃ (6), $[(Me_3SiCH_2)(Br)AlAs(SiMe_3)_2]_2(7), \text{ and } [(Me_3SiCH_2)_2AlAs(SiMe_3)_2]_2(9).$

	2	E	4	v.	پ	٢	6
formula	C21H60AlAsSi6	C24H60AIPSi3	C24H60AlAsSi3	C ₁₇ H ₄₀ AlBrPSis	 CaHsaAlyBr2P,Sia	CuHsAlyAsyBrySia CaHsuAlyAsySis	C3H80AlyAS,Sig
formula weight	583.11	490.94	534.89	531.87	742 92	830.82	8.15.44
space group	$P3_1$	P3	<i>P</i> 3	P2,/c	P2,/c	121/6	Phen .
a, Å	16.1093(25)	16.1189(12)	16.182(2)	12.847(1)	9 791(1)	6 850(1)	12 852(3)
b, A	ļ	1	-	12.671(2)	19.392(3)	16 627(3)	(2)50012
c, Å	12.0895(12)	11.285(2)	11.415(1)	20.573(3)	11415(1)	11 452(1)	18 580(1)
β, deg	1	1		103.07(1)	111 782(9)	112.057(9)	;
V, ų	2717.0(5)	2539.1(4)	2589.4(7)	3262.8(8)	2012.6(3)	2051.9(4)	5038(1)
2	3	3	.3	4	2	2	₩.
crystal color, habit	colorless block	coloriess block	colorless block colorless block colorless block	colorless block	colorless block	colorless block	colorless block

Table 1. (Continued)

D(calc), g cm	1.069	0.963	1 029	1.083	1 226	1 345	1115
$\mu(MoK\alpha)$, cm ⁻¹	11.6	2.22	11.23	15.22	23 26	38.04	15 68
temp, K	138	233(2)	233(2)	298(2)	298(2)	298(2)	251(2)
radiation			Μοκα (λ	$Mok\alpha (\lambda = 0.71073 A)$			
R(F), %a	4.4	4 99	7.88	9.38	4 92	67.5	3.41
$R(wF^2)$, %	5.6	12 00	15.98	17.98	10 02	14.17	6.94
a Quantity minim	$(\operatorname{zed} = R(wP^2) - \Sigma)$	a Quantity minimized = $R(wL^2) = \Sigma [w(U_o^2 - U_o^2)^2] / \Sigma [(wU_o^2)^2]^2$; $R = \Sigma N \Sigma (U_o) / \Delta = \{(U_o - U_o)\}$	7'': R 2N/3H	[(.//)] - V ()			

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Table 2. Selected bond lengths (Å) and angles (°) for 2, 3, 4, 5, 6, 7, and 9, with Estimated Standard Deviations in Parentheses.

	Bond Length	ns			
Al(1)-As(1)	2.671(3)	As(1)-Si(1)	2.377(3)		
Al(1)-C(41)	1.985(9)	As(1)-Si(2)	2.367(3)		
Al(1)-C(51)	2.009(10)	As(1)-Si(3)	2.371(3)		
Al(1)-C(61)	1.989(10)				
Bond Angles					
Al(1)-As(1)-Si(1)	111.15(10)	As(1)-Al(1)-C(41)	101.2(3)		
Al(1)-As(1)-Si(2)	116.15(10)	As(1)-Al(1)-C(51)	99.2(3)		
Al(1)-As(1)-Si(3)	114.17(10)	As(1)-Al(1)-C(61)	102.5(3)		
Si(1)-As(1)-Si(2)	104.34(11)	C(41)-Al(1)-C(51)	115.7(4)		
Si(1)-As(1)-Si(3)	105.57(10)	C(41)-Al(1)-C(61)	116.2(4)		

C(51)-Al(1)-C(61)

117.4(4)

104.45(10)

Si(2)-As(1)-Si(3)

Table 2. (continued)

Bond	Lengths
------	---------

Al-P	2.681(4)	P-Si	2.278(2)
Al-C(4)	1.996(4)		
	Bond A	ngles	
Al-P-Si	112.93(7)	P-Al-C(4)	95.3(2)
Si-P-SiA	105.80(8)	C(4)-Al-C(4A)	119.17(5)

4

Al-As

Bond Lengths

2.72(2)

As-Si

2.363(7)

Al-C(4)	1.97(2)		
	Bond A	Angles	
Al-As-Si	114.3(2)	As-Al-C(4)	97.0(9)
Si-As-SiA	104.3(3)	C(4)-Al-C(4A)	118.5(3)

Table 2. (continued)

Bond Lengths	Bond	Lengths
--------------	------	---------

Al-P	2.498(7)	P-Si(3)	2.271(6)
Al-Br	2.351(5)	P-Si(4)	2.306(6)
Al-C(1)	1.97(2)	P-Si(5)	2.286(7)
Al-C(5)	1.96(2)		
	Bond Angles	3	
Al-P-Si(3)	110.5(2)	P-Al-Br	100.7(2)
Al-P-Si(4)	113.2(3)	P-Al-C(1)	104.4(6)
Al-P-Si(5)	111.7(2)	P-Al-C(5)	107.0(5)
Si(3)-P-Si(4)	107.4(2)	Br-Al-C(1)	109.2(5)
Si(3)-P-Si(5)	107.7(3)	Br-Al-C(5)	113.4(6)
Si(4)-P-Si(5)	106.1(3)	C(1)-Al-C(5)	119.9(7)

6

Bond Lengths

Al(1)-P(1)	2.436(2)	Al(1)-P(1A)	2.435(3)
Al(1)-Br(1)	2.312(2)	Al(1)-C(7)	1.941(7)
P(1)-Si(1)	2.276(3)	P(1)-Si(2)	2.273(3)

Table 2. (continued)

Bond Angles

Al(1)-P(1)-Al(1A)	89.42(8)	P(1)-AI(1)-P(1A)	90.58(8)
Br(1)-Al(1)-P(1)	105.55(9)	C(7)-Al(1)-P(1)	121.9(2)
Br(1)-Al(1)-P(1A)	108.55(10)	C(7)-Al(1)-P(1A)	114.1(2)
Br(1)-Al(1)-C(7)	113.5(2)	Si(1)-P(1)-Si(2)	107.58(10)
Si(1)-P(1)-Al(1)	113.18(10)	Si(2)-P(1)-Al(1)	119.65(10)
Si(1)-P(1)-Al(1A)	114.79(10)	Si(2)-P(1)-Al(1A)	111.59(10)

7

Bond Lengths

Al-As	2.505(3)	Al-AsA	2.515(3)		
Al-Br	2.316(3)	Al-C(4)	1.955(10)		
As-Si(2)	2.364(3)	As-Si(3)	2.362(3)		
Bond Angles					
Al-As-AlA	90.15(9)	As-Al-AsA	89.85(9)		
Br-Al-As	105.52(11)	C(4)-Al-As	122.3(3)		
Br-Al-AsA	107.99(12)	C(4)-Al-AsA	113.9(3)		
Br-Al-C(4)	114.2(3)	Si(2)-As-Si(3)	107.23(11)		
Si(2)-As-Al	119.65(10)	Si(3)-As-Al	113.05(10)		
Si(2)-As-AlA	111.45(10)	Si(3)-As-AlA	114.85(10)		

Table 2. (continued)

Bond Lengths

Al(1)-As	2.567(2)	Al(2)-As	2.560(2)		
Al(1)-C(4)	1.962(4)	Al(2)-C(8)	1.965(4)		
As-Si(3)	2.358(2)	As-Si(4)	2.357(2)		
Bond Angles					
Al(1)-As-Al(2)	92.85(4)	As-Al(1)-AsA	86.99(7)		
As-Al(2)-AsA	87.31(6)	C(4)-Al(1)-C(4A)	122.1(3)		
C(4)-Al(1)-As	115.7(2)	C(4)-Al(1)-AsA	105.54(13)		
C(8)-Al(2)-C(8A)	122.2(3)	C(8)-Al(2)-As	113.7(2)		
C(8)-Al(2)-AsA	107.29(14)	Si(3)-As-Si(4)	104.04(6)		
Si(3)-As-Al(1)	111.40(5)	Si(3)-As-Al(2)	116.03(5)		
Si(4)-As-Al(1)	121.42(5)	Si(4)-As-Al(2)	111.61(5)		

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